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FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE. PATENT AND TRADEMARK OFFICE	ATTY, DOCKET NO. MICRON.0950V2C1	APPLICATION NO.  HARMONT  LO/679, 822
INFORMATION B	DISCLOSURE STATEMENT Y APPLICANT	APPLICANT Agarwal, et al.	
(USE SEVERA	L SHEETS IF NECESSARY)	FILING DATE	GROUP 2823

			U.S. PATENT DOCUMENTS	CLASS	SUBCLASS	FILING DATE
AMINER	DOCUMENT NUMBER	DATE	NAME			(IF APPROPRIATE)
	4,761,386	8/2/88	Buynoski			
1	4,823,182	4/18/89	Okumura			
	4,884,123	11/28/89	Dixit, et al.			
	4,895,770	1/23/90	Schintlmeister, et al.		-	
	4,920,071	4/24/90	Thomas		-	
	5,225,771	7/6/93	Leedy		-	
	5,248,903	9/28/93	Heim		<del>                                     </del>	
	5,298,333	3/29/94	Maixner, et al.			
	5,364,803	11/15/94			-	
	5,391,516	2/21/95	Wojnarowski, et al.		-	·
	5,441,904	8/15/95	Kim, et al.			
	5,486,492	1/23/96	Yamamoto, et al.			
	5,506,499	4/9/96	Puar		_	
	5,541,427	7/30/96	Chappell, et al.			
	5,593,903	1/14/97	<del></del>			
	5,668,394	9/16/97				
	5,684,304	11/4/97				
	5,693,377	12/2/97				
	5,720,098	2/24/9			_	
	5,742,174	4/21/9				
	5,837,598	11/17/	98 Aronowitz, et al.		_	
	5,851,680	12/22/			_	
	5,920,081	7/6/99	Chen, et al.			
	5,962,867	10/5/9				
-	5,968,594		/99 Hu, et al.			
	5,994,716	11/30	/99 lkeya, et al.			
a	6,028,360	2/22/	Nakamura, et al.			

EXAMINER MULL DATE CONSIDERED 3/2/2005

\*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.

SHEET 2 OF 2

FORM PTO-1449  U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		E ATTY, DOCKET NO. MICRON.0950V2C1	APPLICATI Unknown		922			
INFORMATION DISCLOSURE STATEMENT BY APPLICANT			APPLICANT Agarwal, et al.					
(USE	SEVERAL SHEETS IF NECESS	ARY)	FILING DATE Herawith 10/6/2003	GROUP 2823				
			U.S. PATENT DOCUMENTS					
XAMINER	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING (IF APPRO	DATE PRIATE)	
INITIAL	6,017,818	1/25/00	Lu					
	6,069,482	5/30/00	Hilton					
(2)	6,133,582	10/17/00	Osann, Jr., et al.					
(D)	6,200,649	3/13/01	Dearnaley					
-	111							
			FOREIGN PATENT DOCUMENTS					
			COUNTRY	CLASS	SUBCLASS	TRANSLATION		
EXAMINER INITIAL	DOCUMENT NUMBER	DATE				YES	NO	
	EP 0854 505 A2	7/22/98	Europe		·			
KIR		•						
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							<del>                                     </del>	
					+	<del> </del>		
EXAMINER		OTHER DOCU	MENTS (INCLUDING AUTHOR, TITLE, DATE, PERTI	NENT PAGES	S, ETC.)			
INITIAL (A)	IY-Ray Absorbtion Fine	Structure ii	otoelectron/auger Electron Spectroscopy/onvestigation of TiBxNy Coatings*. J. Vac.					
(A)	Sade, et al., "Characte Vol. 402, pp. 131-136,	rization of T 1996	iB2/TiSi2 Bilayer Structure Deposited By	Sputtering" 	, Mat. Kes.	300. 3111		
1	Voi. 402, pp. 10 1 100							
H:\DOCS\KJ	L\KJL-2351.DOC							

DATE CONSIDERED

\*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.